

2D electronic phases intermediate between the Fermi liquid and the Wigner crystal (electronic micro-emulsions)

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Electron interaction can be characterized by a parameter

$$r_s = E_{\text{pot}} / E_{\text{kin}}$$

$$E_{\text{kin}} \propto n \quad E_{\text{pot}} \propto n^{g/2}$$
$$r_s \propto n^{\frac{g-2}{2}}$$

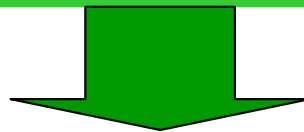
(e-e interaction energy is $V(r) \sim 1/r^g$)

Electrons ($g=1$) form Wigner crystals at $T=0$ and small n
when $r_s \gg 1$ and $E_{\text{pot}} \gg E_{\text{kin}}$

${}^3\text{He}$ and ${}^4\text{He}$ ($g>2$) are crystals at large n

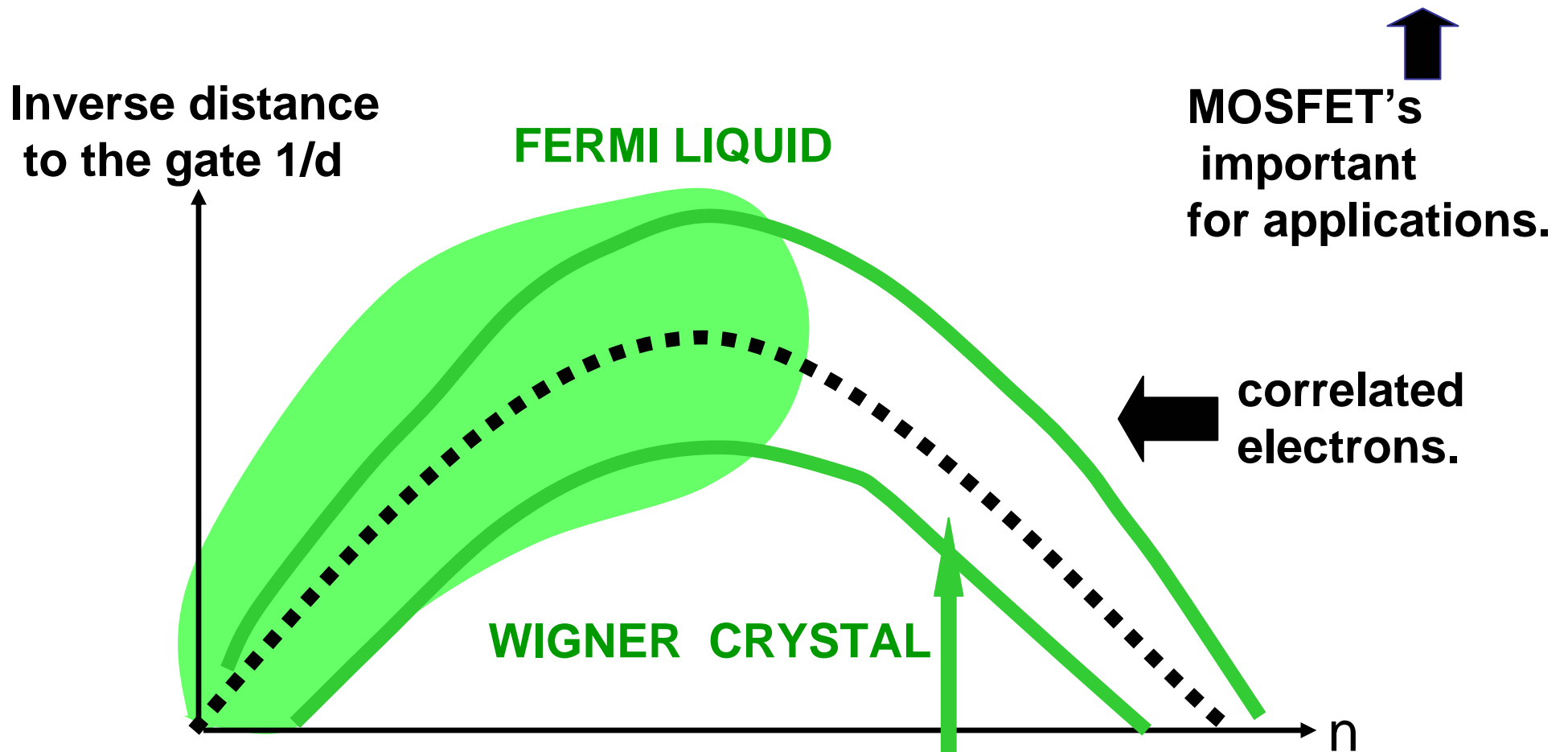
- a. Transitions between the liquid and the crystal should be of first order.**

- b. As a function of density 2D first order phase transitions in systems with dipolar or Coulomb interaction are forbidden.**



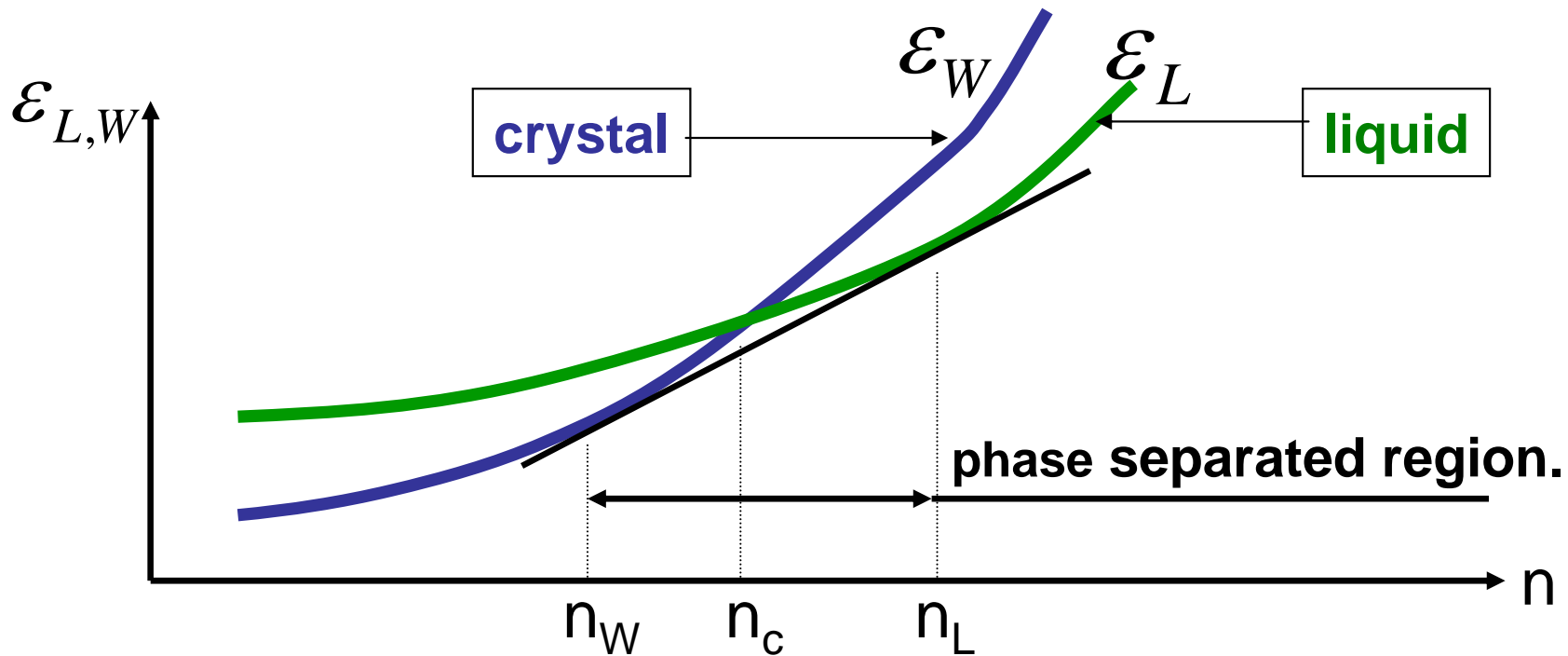
There are 2D electron phases intermediate between the Fermi liquid and the Wigner crystal (micro-emulsion phases)

Phase diagram of 2D electrons in MOSFET's . ($T=0$)



In green areas where quantum effects are important.

Phase separation in the electron liquid.



There is an interval of electron densities $n_W < n < n_L$ near the critical n_c where phase separation must occur

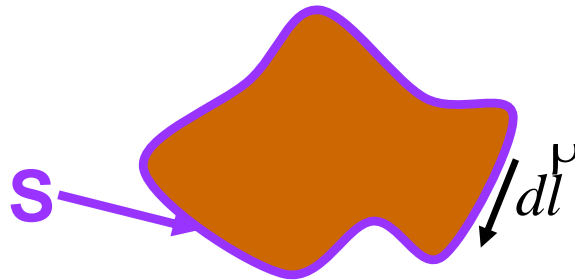
To find the shape of the minority phase one must minimize the surface energy at a given area of the minority phase

the case of dipolar interaction

$$E_{surf} = \int_S \gamma(\theta) dl - a \int_S \frac{dl^\rho dl'^\rho}{|l - l'|} \approx$$

$$\gamma L - a L \ln \frac{L}{d}$$

$\gamma > 0$ is the microscopic surface energy



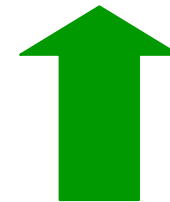
At large L the surface energy is negative!

Elementary explanation: Finite size corrections to the capacitance

$$C = \frac{R^2}{d} + R \ln \frac{16\pi R}{d}$$

R is the droplet radius

$$E_c = \frac{Q^2}{2C} = \frac{(enR^2)^2}{2C} \propto (en)^2 R^2 d - (en)^2 R \ln \frac{R}{d}$$



This contribution to the surface energy is due to a finite size correction to the capacitance of the capacitor. It is negative and is proportional to $-R \ln (R/d)$

Coloumb case

$$E = \mu[n_0 - n_c][S_+ - S_-] + \int dl^\rho \gamma(\theta) - \frac{\mu^2}{e} \int \frac{dl^\rho dl'^\rho}{|l - l'|},$$

S_+ and S_- are area of the minority and the majority phases,
 n_0 and n_c are average and critical densities,

$$\mu = \frac{d(\varepsilon_L - \varepsilon_W)}{d n}$$

At large area of a minority phase the surface energy is negative.



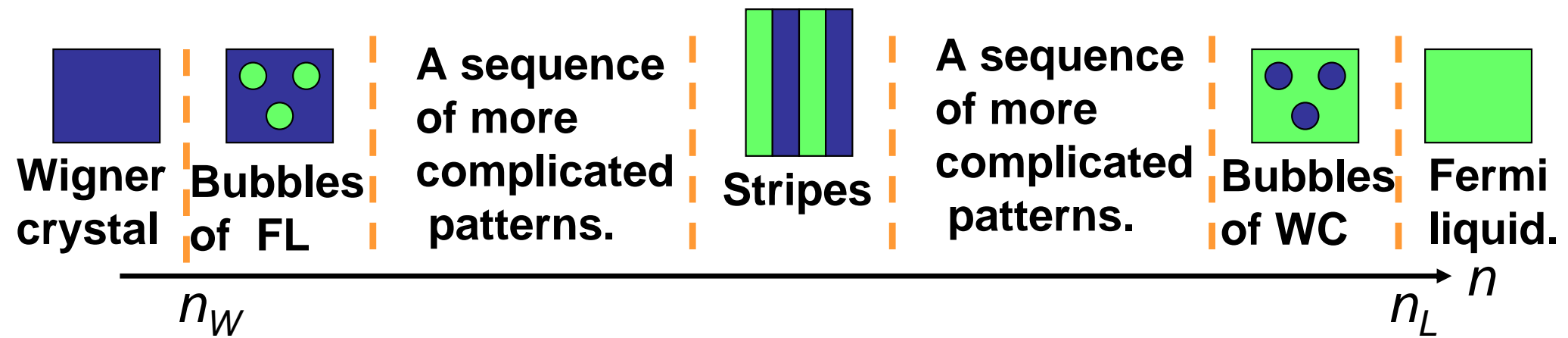
Single connected shapes of the minority phase are unstable. Instead there are new electron micro-emulsion phases.

The characteristic size of the droplets is

$$R \propto de^\alpha,$$

$$\alpha = \frac{4\pi\gamma}{e^2(n_W - n_L)^2} \geq 1, \quad \gamma = \frac{d}{dn} [\varepsilon_L - \varepsilon_W]$$

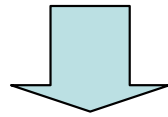
Mean field phase diagram of microemulsions



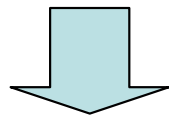
**Transitions are continuous.
They are similar to Lifshitz points.**

**T and H_{\parallel} dependences of the crystal's area.
(Pomeranchuk effect).**

The entropy of the crystal is of spin origin and much larger than the entropy of the Fermi liquid.



$$S_W \gg S_L; \quad M_W \gg M_L$$

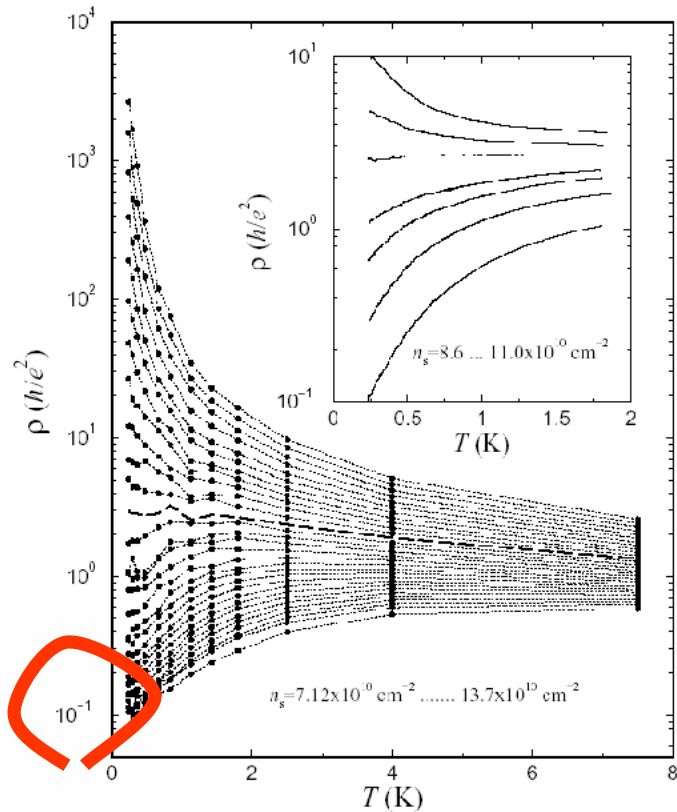


- a. As T and H_{\parallel} increase, the crystal fraction grows.**
- b. At large H_{\parallel} the spin entropy is frozen and the crystal fraction is T- independent.**

**Several experimental facts suggesting
non-Fermi liquid nature 2D electron liquid
at small densities :**

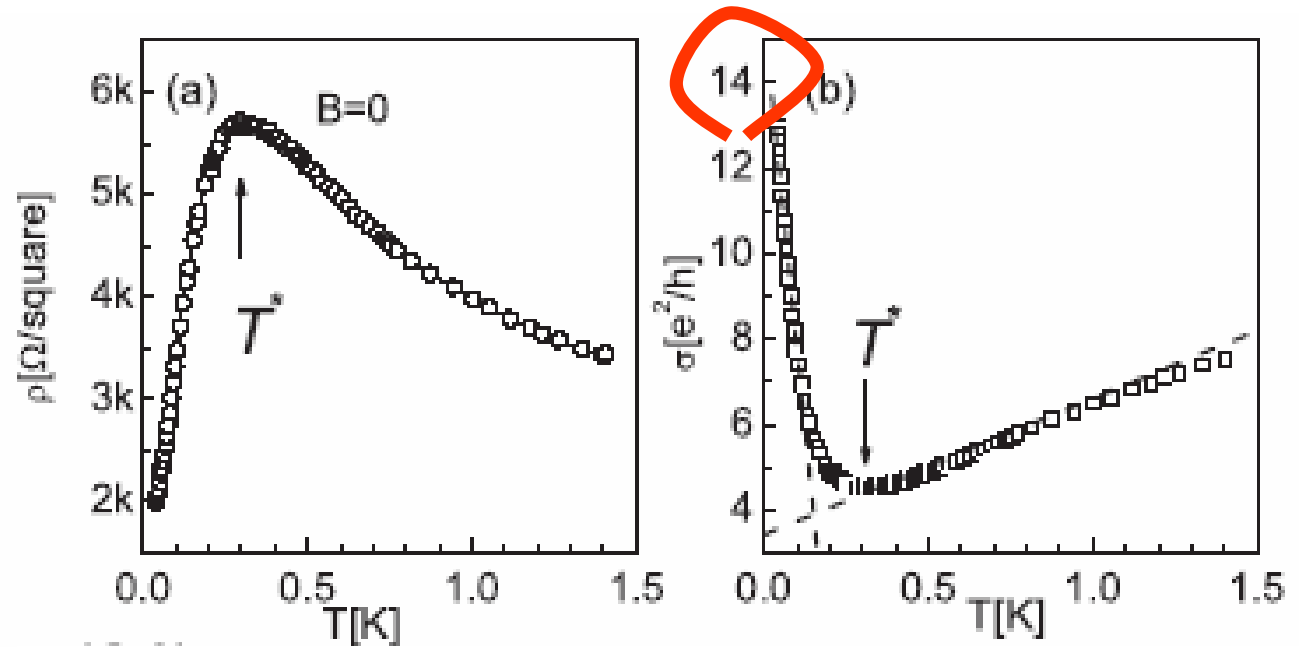
T-dependence of the resistance of 2D electrons at large r_s in the “metallic” regime ($G \gg e^2/h$)

Kravchenko et al



Si MOSFET

Gao et al, Cond. mat 0308003



p-GaAs, $p = 1.3 \cdot 10^{18} \text{ cm}^{-3}$; $r_s = 30$

T-dependence of the resistance of 2D p-GaAs layers at large r_s in the “metallic” regime .

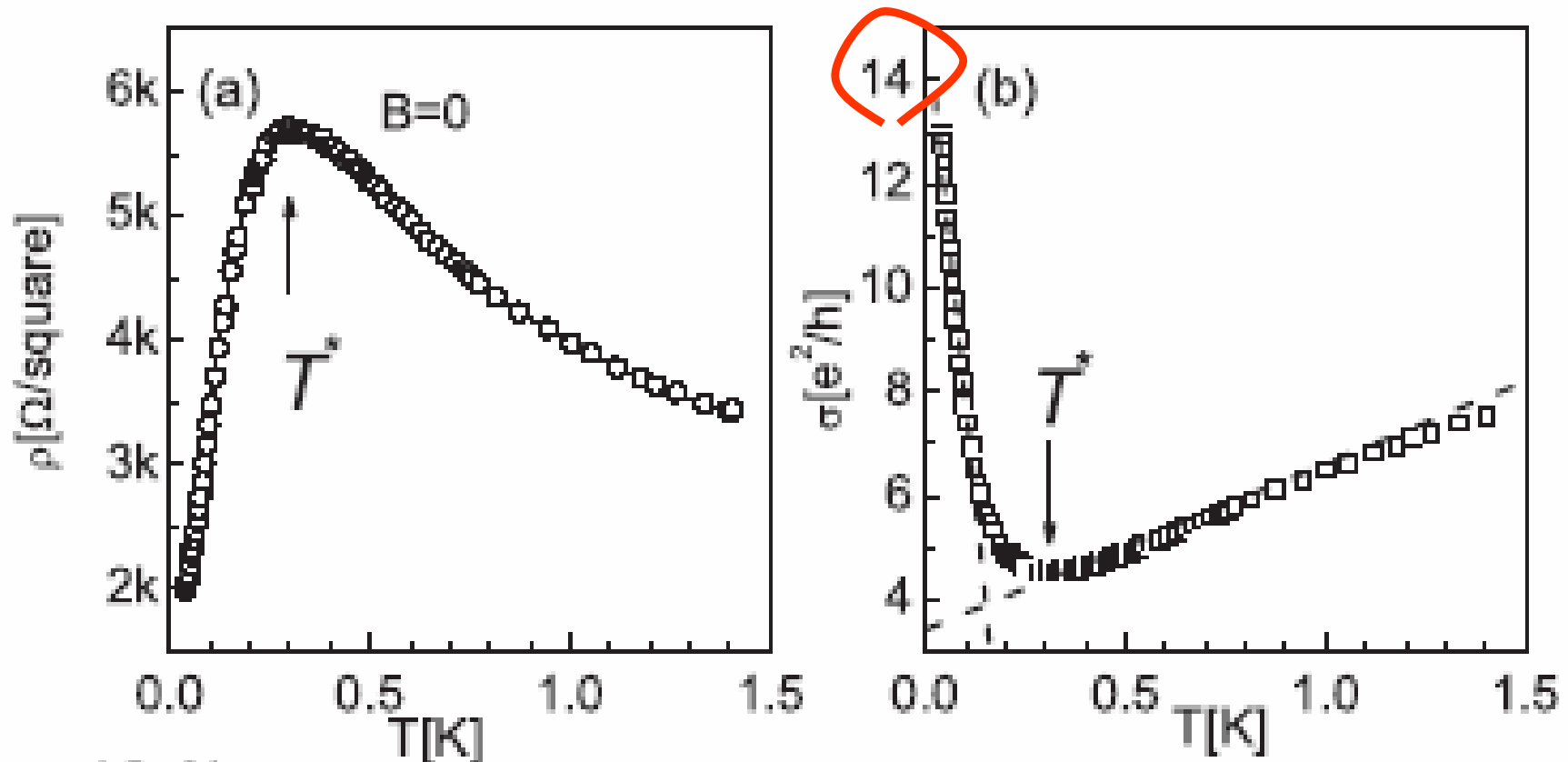
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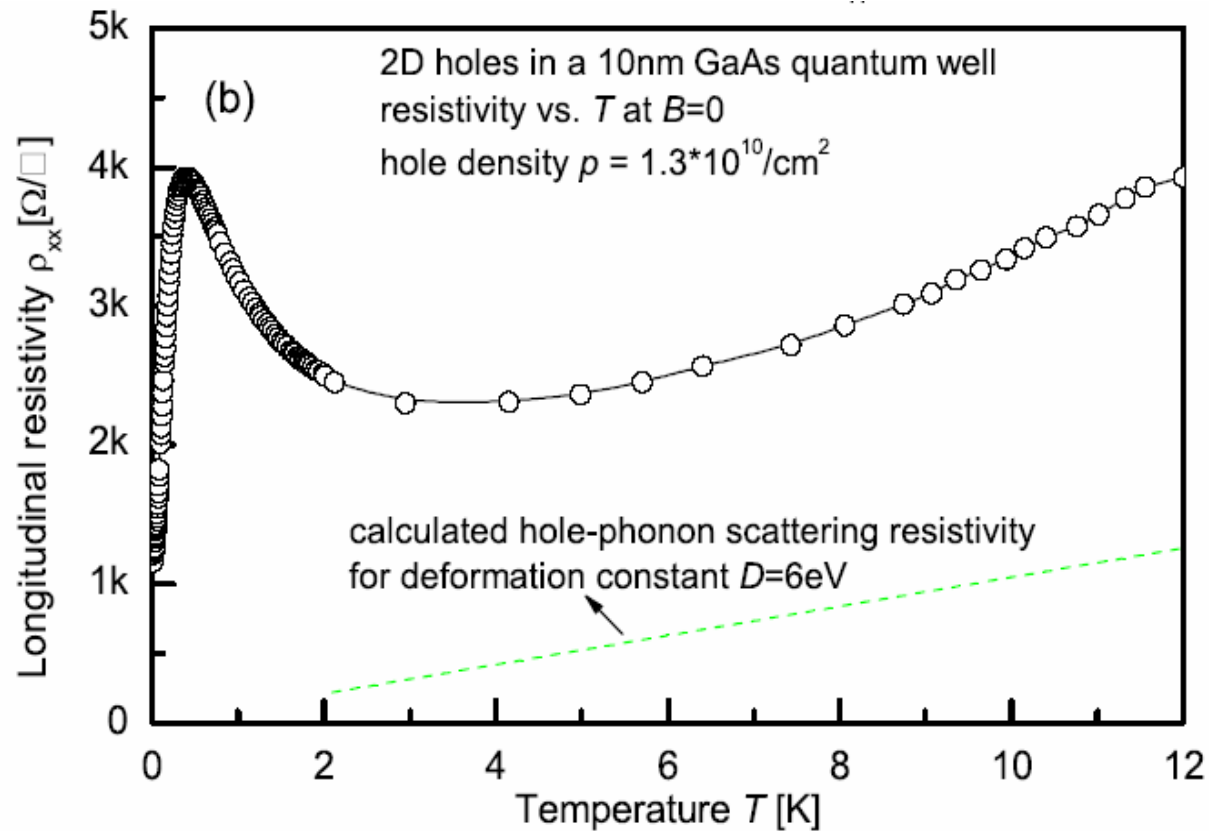
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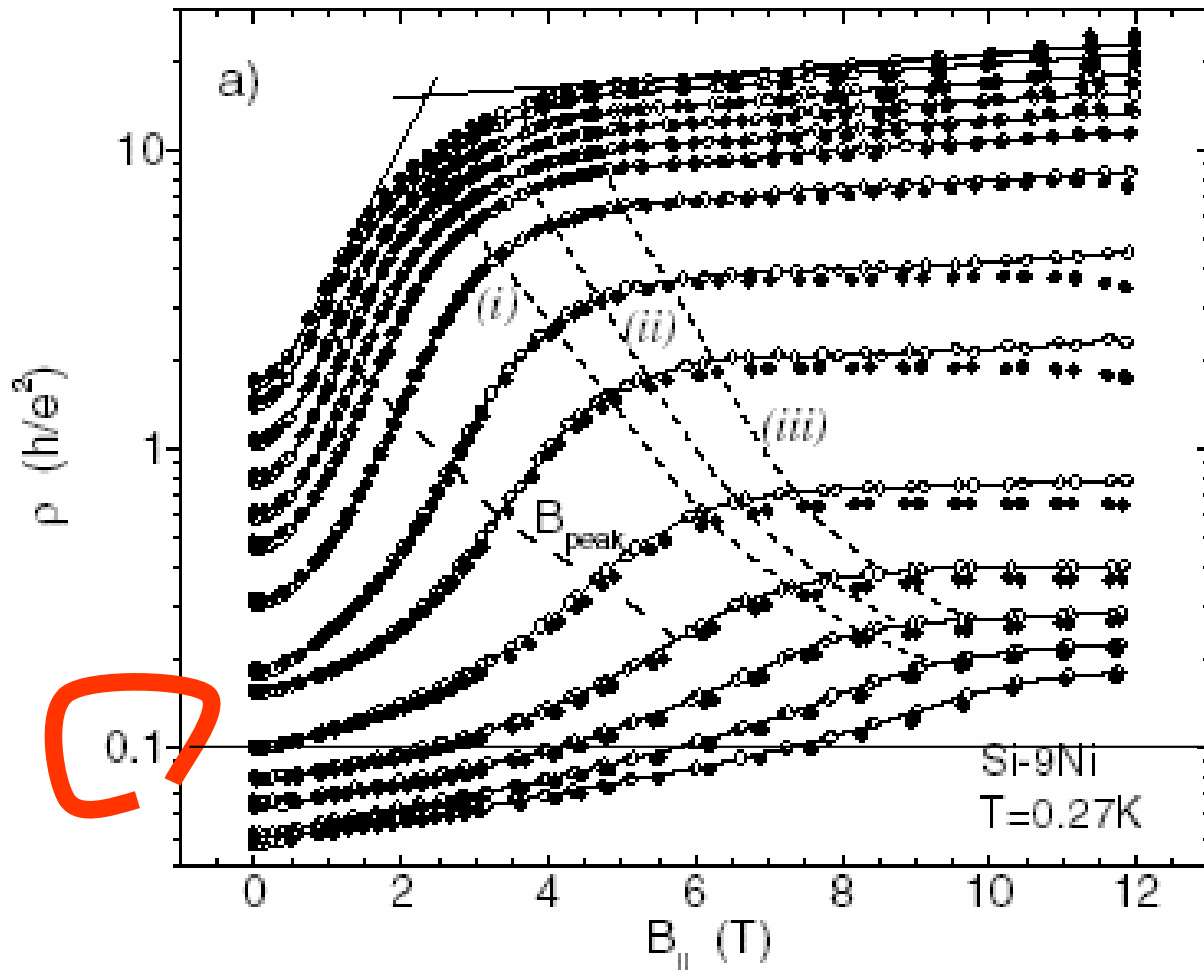


$$\underline{P=1.3 \cdot 10^{10} \text{ cm}^{-2} ; \quad r_s=30}$$

Cond-mat/0501686



$B_{||}$ dependences of the resistance of Si MOSFET's at different electron concentrations.

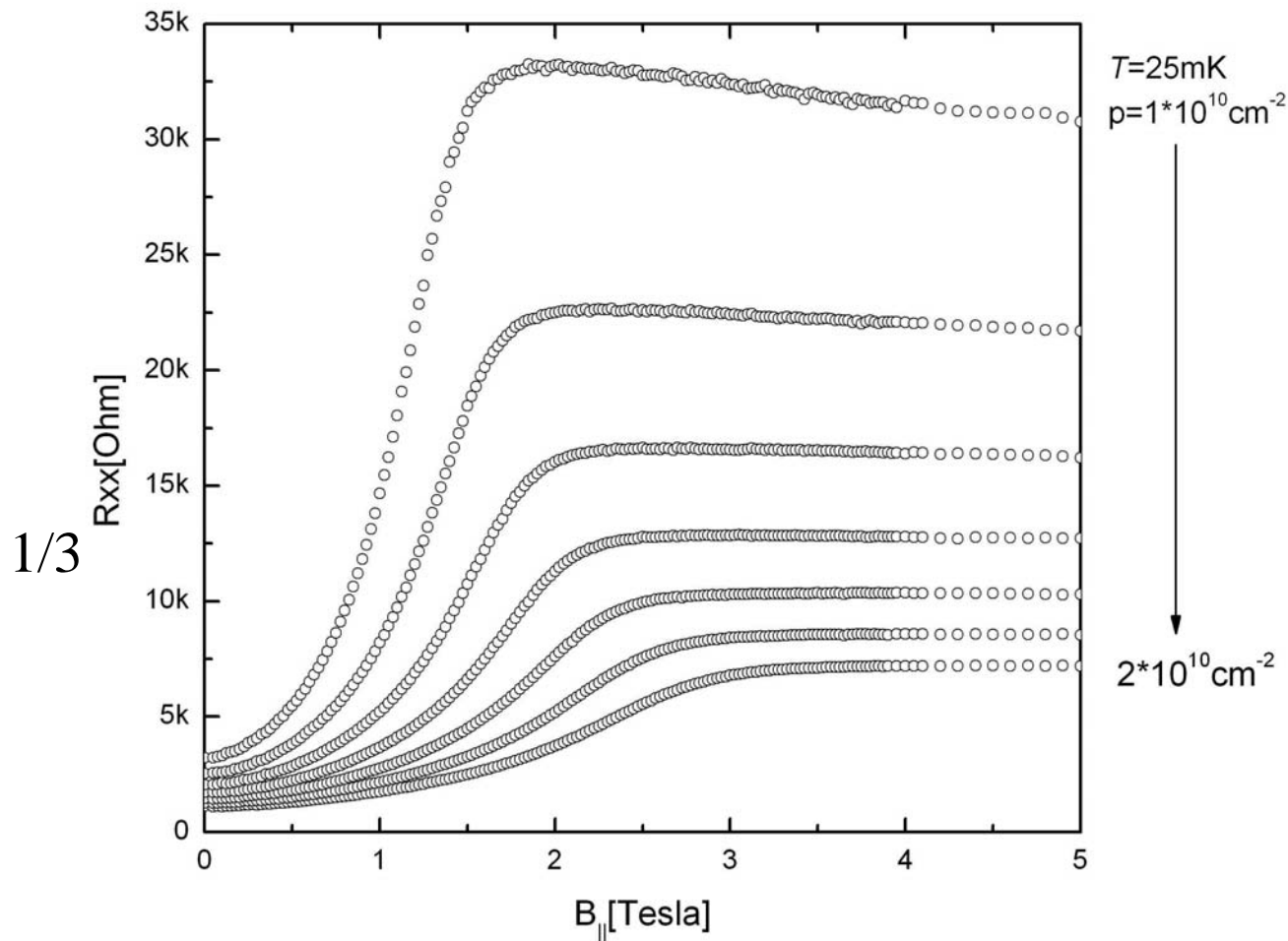


Pudalov et al.

A factor of order 6.

There is a big positive magneto-resistance which saturates at large magnetic fields parallel to the plane.

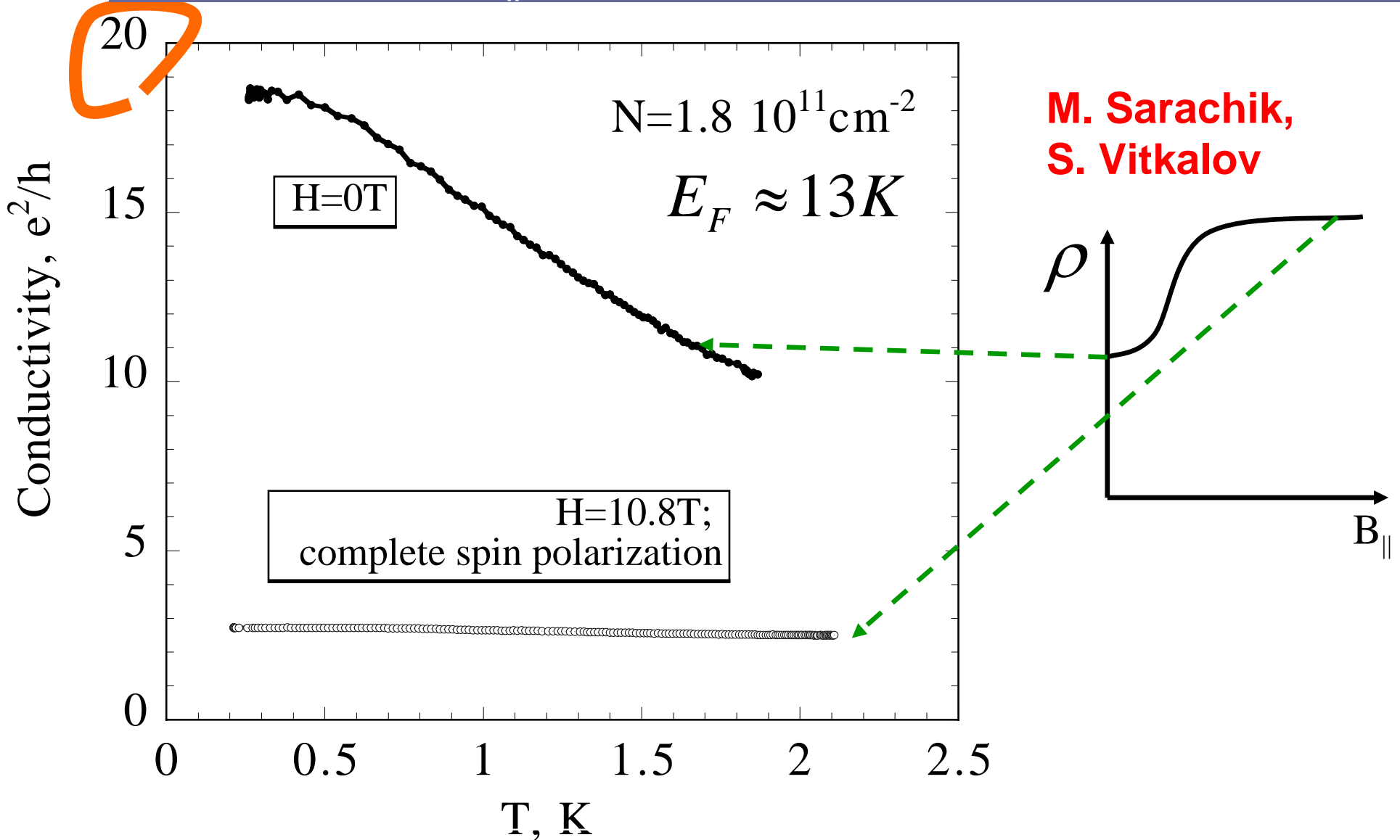
B_{\parallel} dependence of 2D p-GaAs at large r_s and small wall thickness.



Gao et al

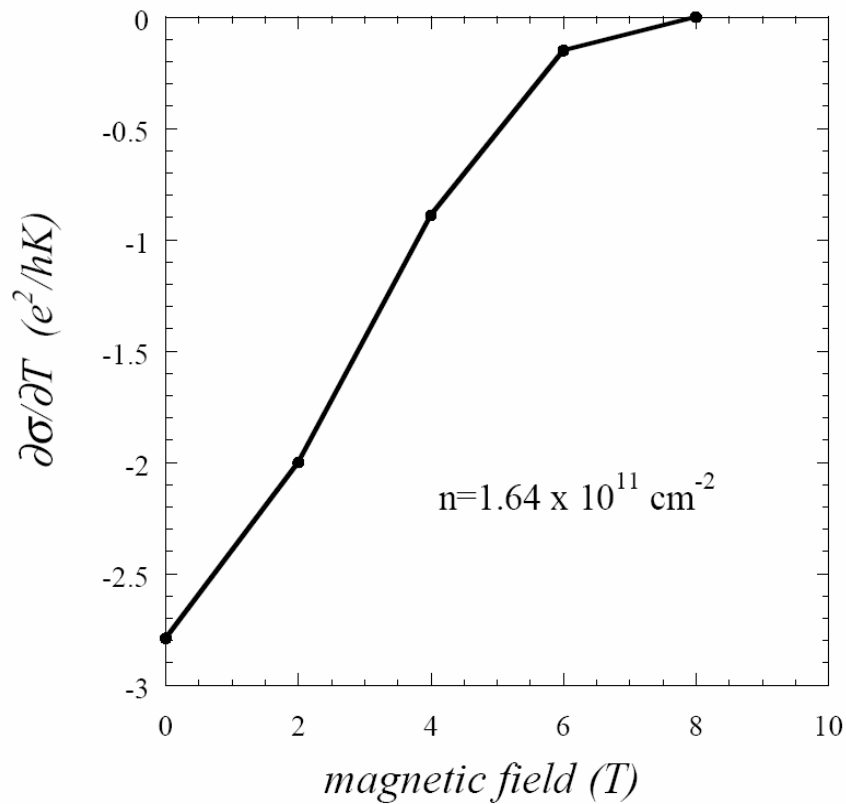
There is a big positive magneto-resistance which saturates at large magnetic fields parallel to the plane.

Comparison T-dependences of the resistances of Si MOSFET's at zero and large B_{\parallel}

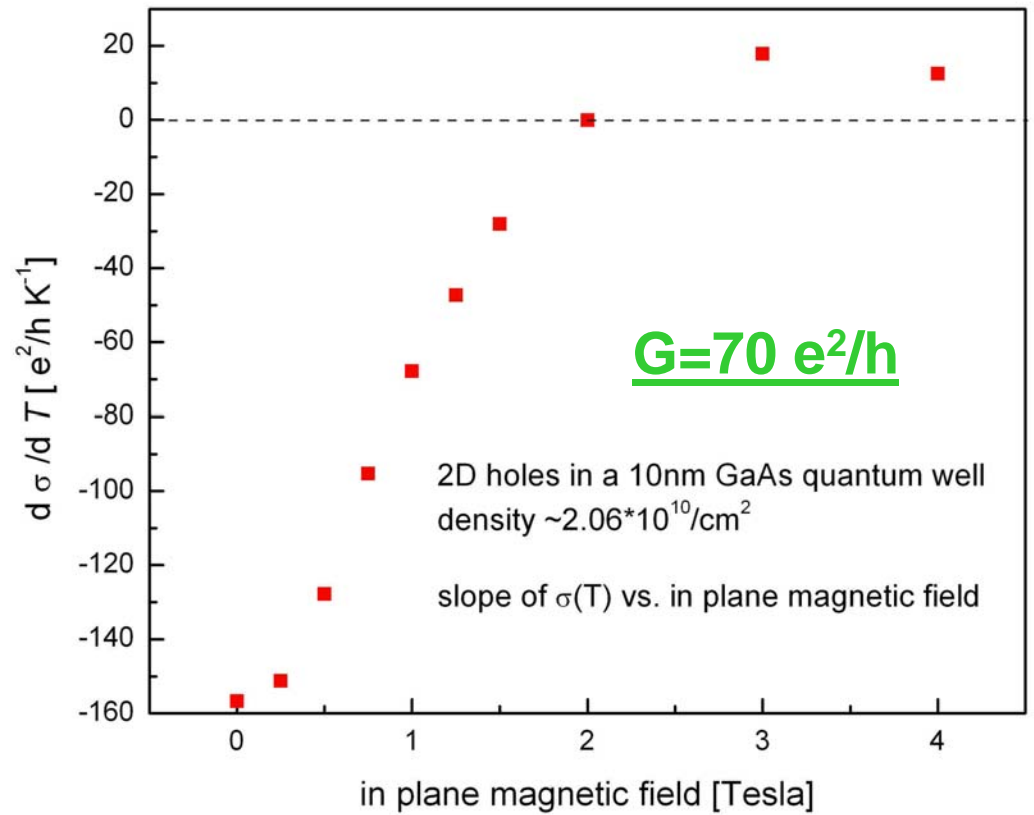


M. Sarachik,
S. Vitkalov

The parallel magnetic field suppresses the temperature dependence of the resistance of the metallic phase. The slopes differ by a factor 100 !!



Tsui et al. cond-mat/0406566

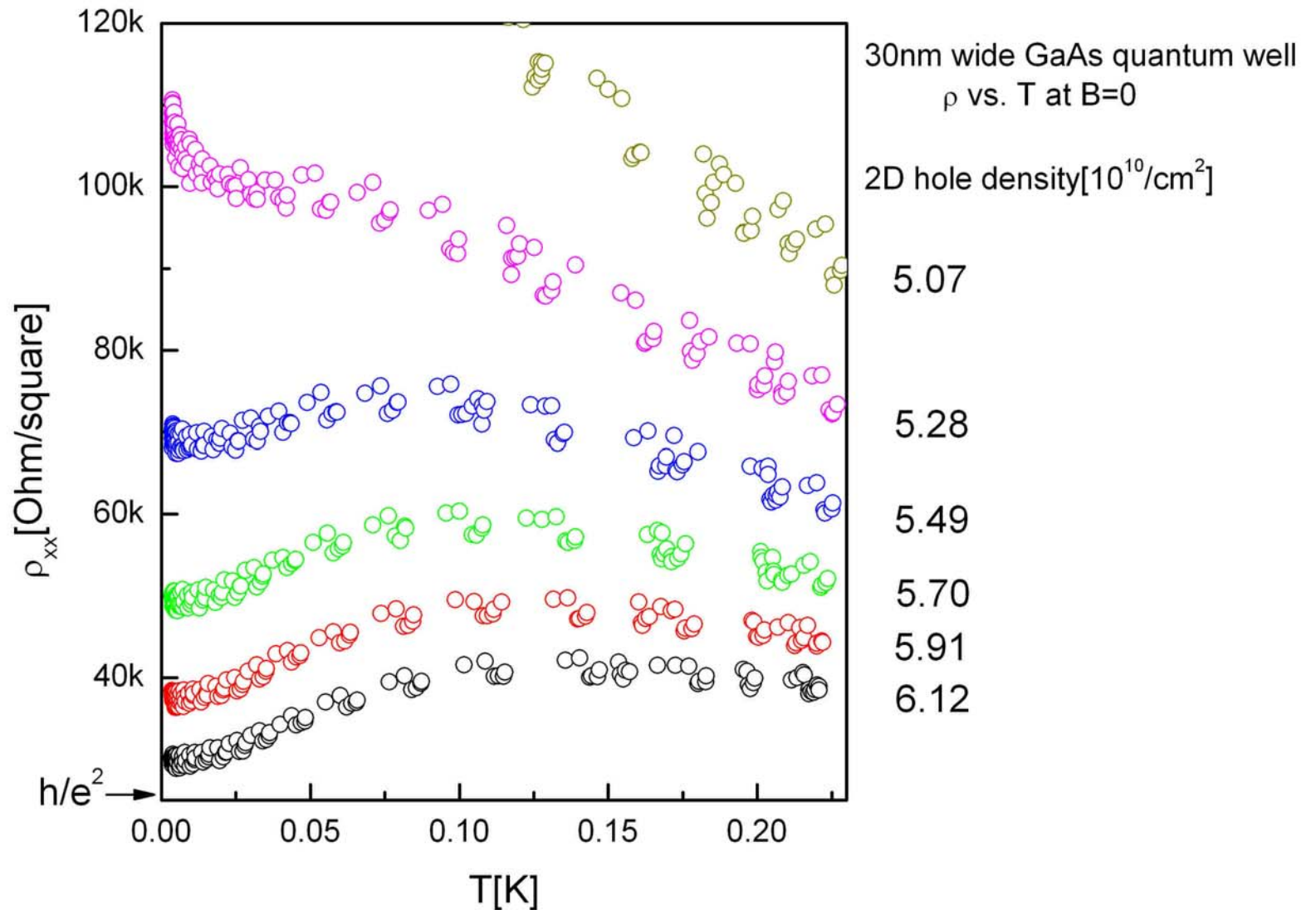


Gao et al

The slope of the resistance dR/dT is dramatically suppressed by the parallel magnetic field.

It changes the sign. Overall change can as much as factor 50 in Si MOSFET's and a factor 10-100 in P-GaAs !

Do materials exist where the resistance has dielectric values $R \gg h/e^2$ and yet still increases as the temperature increases ?



If it is all business as usual:

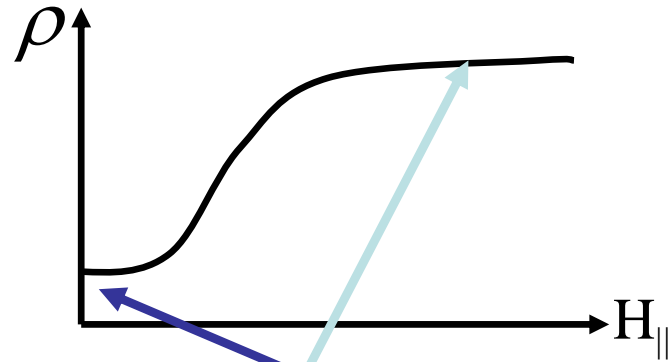
Why is there an apparent metal-insulator transition?

Why is there such strong T and B_{\parallel} dependence at low T, even in “metallic” samples with $G \gg e^2/h$?

Why is the magneto-resistance positive at all?

Why does B_{\parallel} so effectively quench the T dependence of the resistance?

Hopping conductivity regime in MOSFET's Magneto-resistance in the parallel and the perpendicular magnetic field



Kravchenko et al (unpublished)

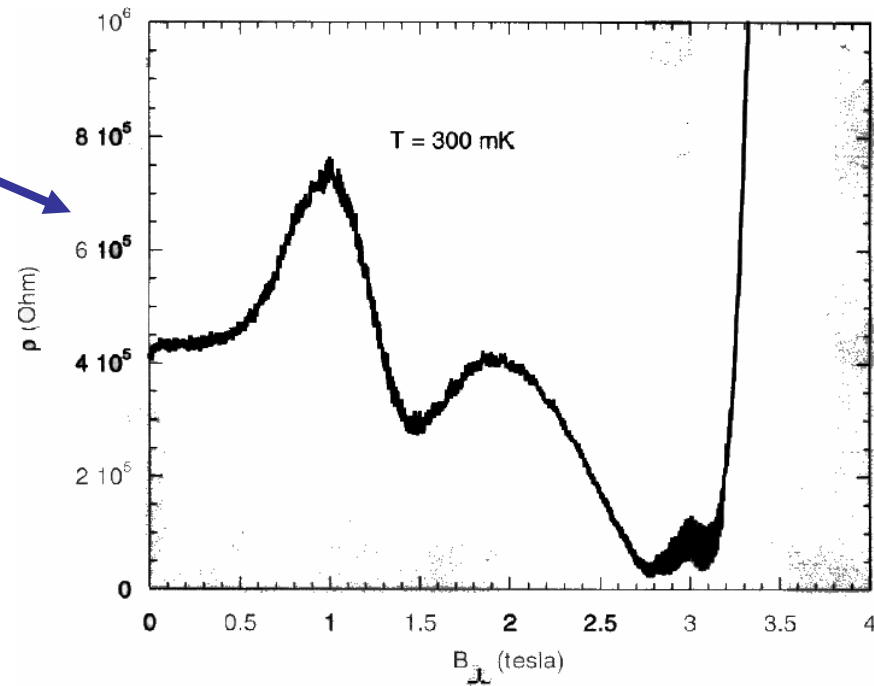
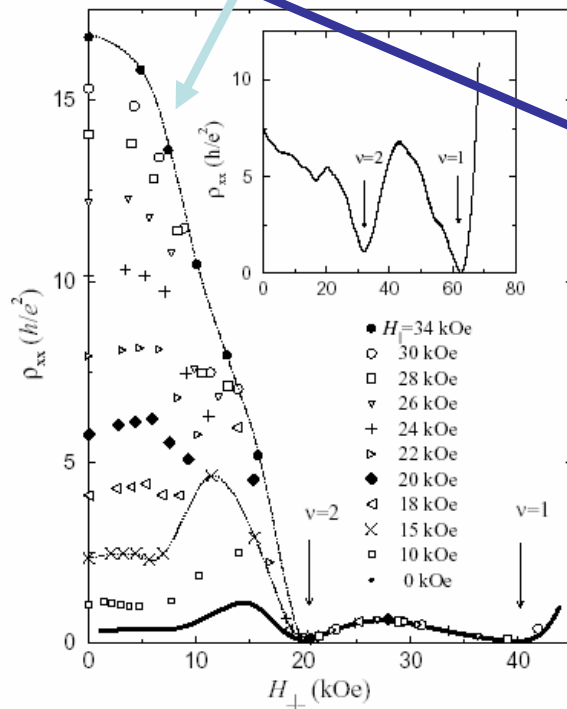
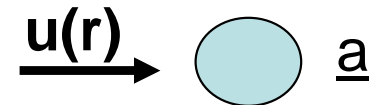


FIG. 3. ρ_{xx} of sample B as a function of H_{\perp} for different values of the parallel magnetic field; $T = 0.36$ K and $n_s = 1.0 \times 10^{11} \text{ cm}^{-2}$. The inset shows $\rho_{xx}(H_{\perp})$ for a low-mobility sample C; $T = 0.36$ K and $n_s = 2.1 \times 10^{11} \text{ cm}^{-2}$.

Connection between the resistance and the electron viscosity $\eta(T)$ in the semi-quantum regime.

The electron mean free path $l_{ee} \sim n^{1/2}$ and hydrodynamics description of the electron system works !

Stokes formula in 2D case: $F \propto \frac{\eta u}{\ln(\eta / nau)}$



$$\rho(T) \propto \eta(T) \frac{N_i}{e^2 n^2 \ln(1 / N_i a^2)}$$

In classical liquids $\eta(T)$ decreases exponentially with T .
In classical gases $\eta(T)$ increases as a power of T .

What about semi-quantum liquids?

If $r_s \gg 1$ the liquid is strongly correlated

$$E_F \ll \Theta = \frac{E_{pot}}{r_s^{1/2}} \ll E_{pot}$$

Θ is the plasma frequency

If $E_F \ll T \ll h\theta \ll E_{pot}$ the liquid is not degenerate but it is still not a gas ! It is also not a classical liquid !

Such temperature interval exists both in the case of electrons with $r_s \gg 1$ and in liquid He

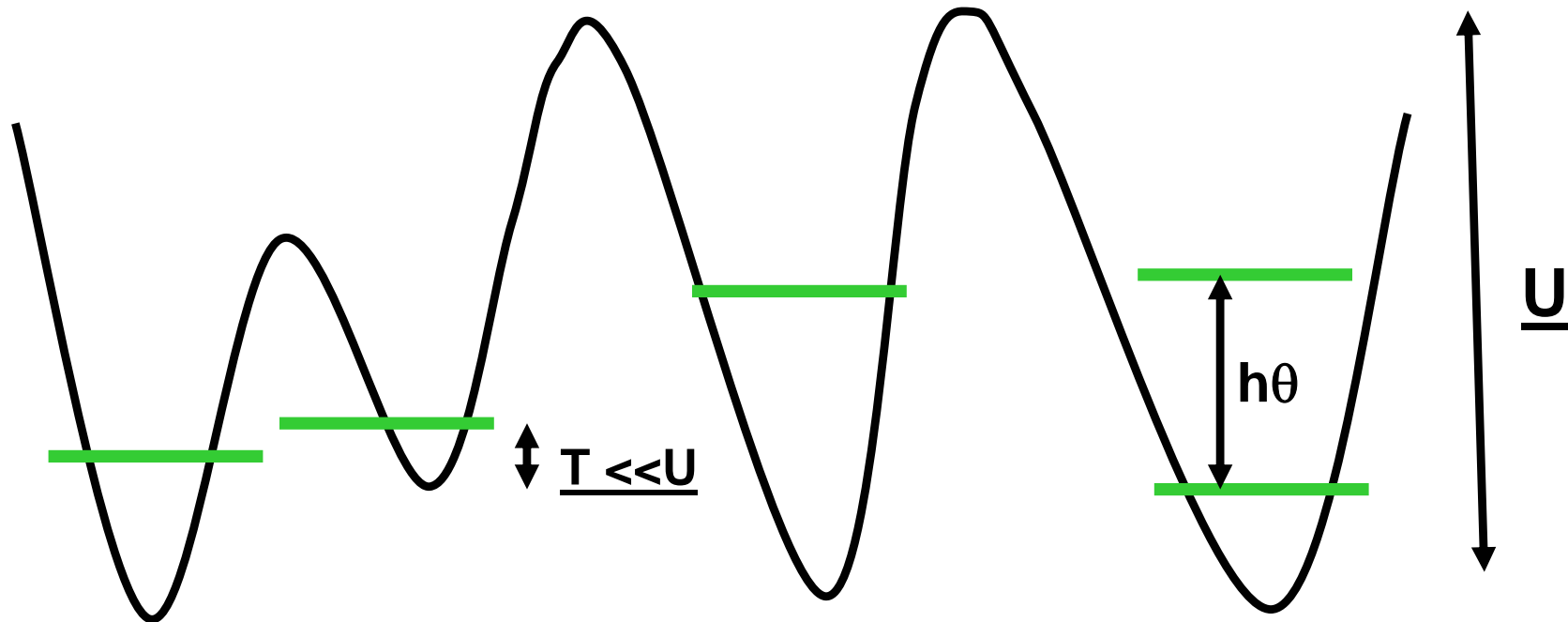
Viscosity of gases ($T \gg U$) increases as T increases

Viscosity of classical liquids ($T_c, h\Theta_D \ll T \ll U$) decreases exponentially with T (Ya. Frenkel)

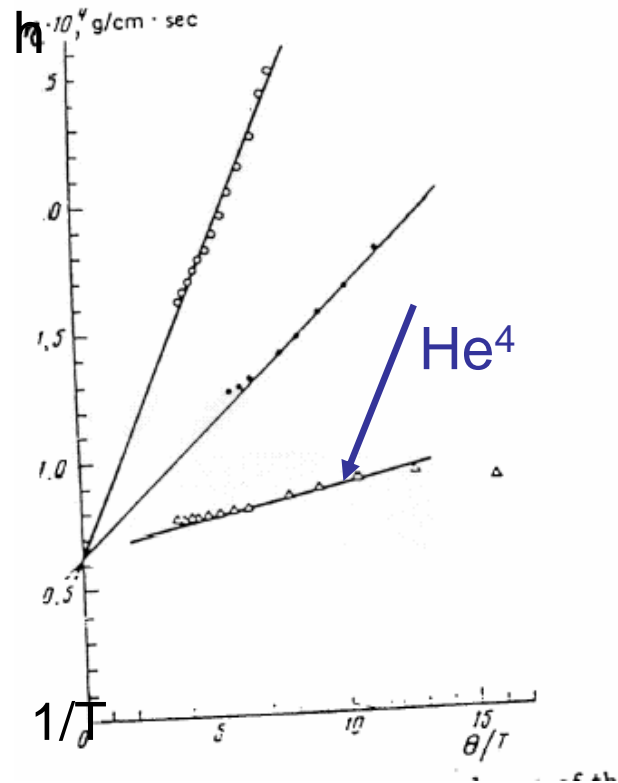
$$\eta \sim \exp(B/T)$$

Semi-quantum liquid: $E_F \ll T \ll h\theta \ll U$: (A.F. Andreev)

$$\eta \sim 1/T$$



Comparison of two strongly correlated liquids:
He³ and the electrons at $E_F < T < E_{pot}$



Experimental data on the viscosity of He³ in the semi-quantum regime ($T > 0.3$ K) are unavailable!?

A theory (A.F.Andreev): $\eta \propto \frac{1}{T}$

T-dependence of the resistance of 2D p-GaAs layers at large r_s in the “metallic” regime .

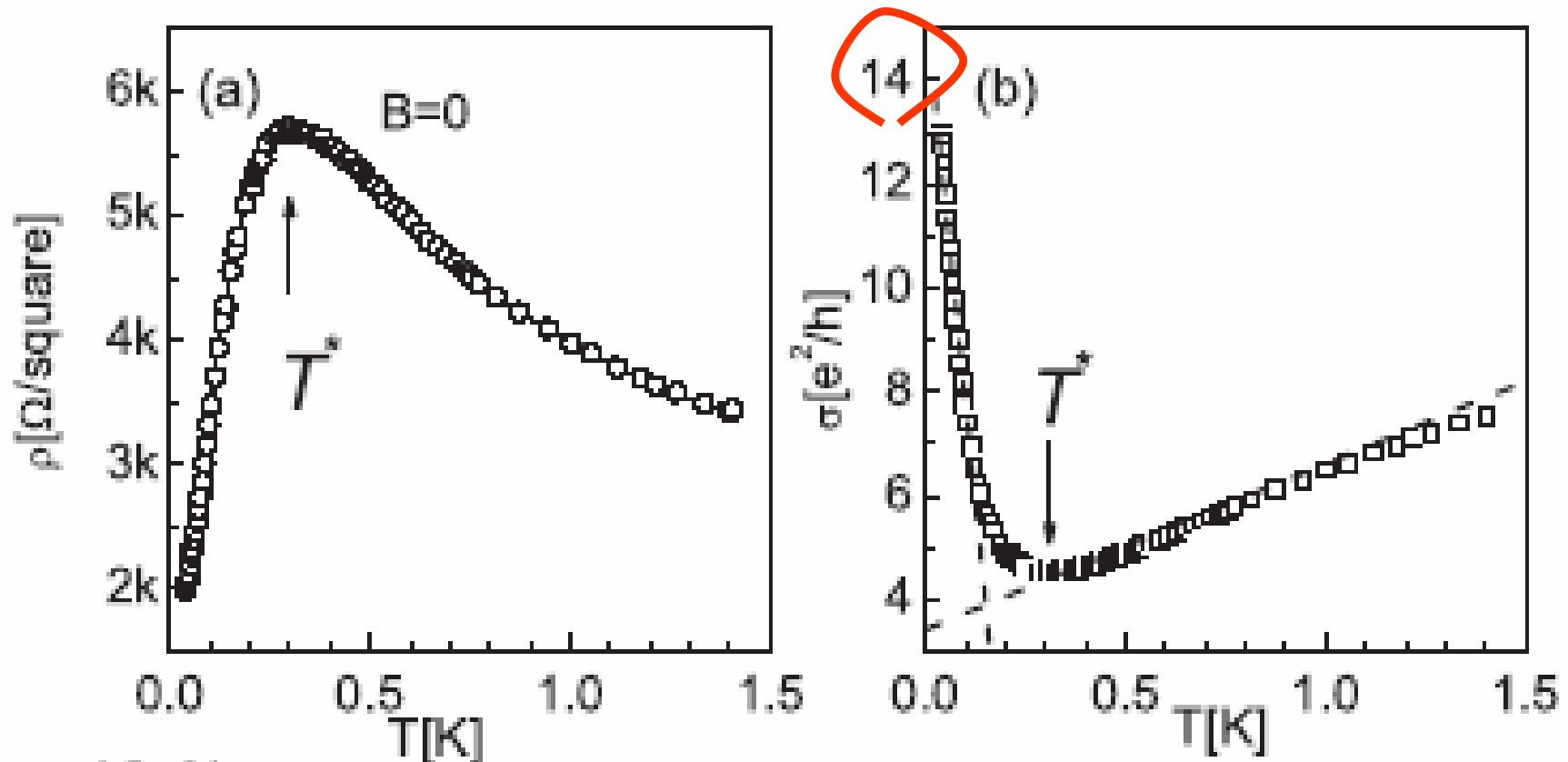
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$$\underline{P=1.3 \cdot 10^{10} \text{ cm}^{-2} ; \quad r_s=30}$$

Experiments on the drag resistance of
the double p-GaAs layers.

B_{\parallel} dependence of the resistance and drag resistance of 2D p-GaAs at different temperatures

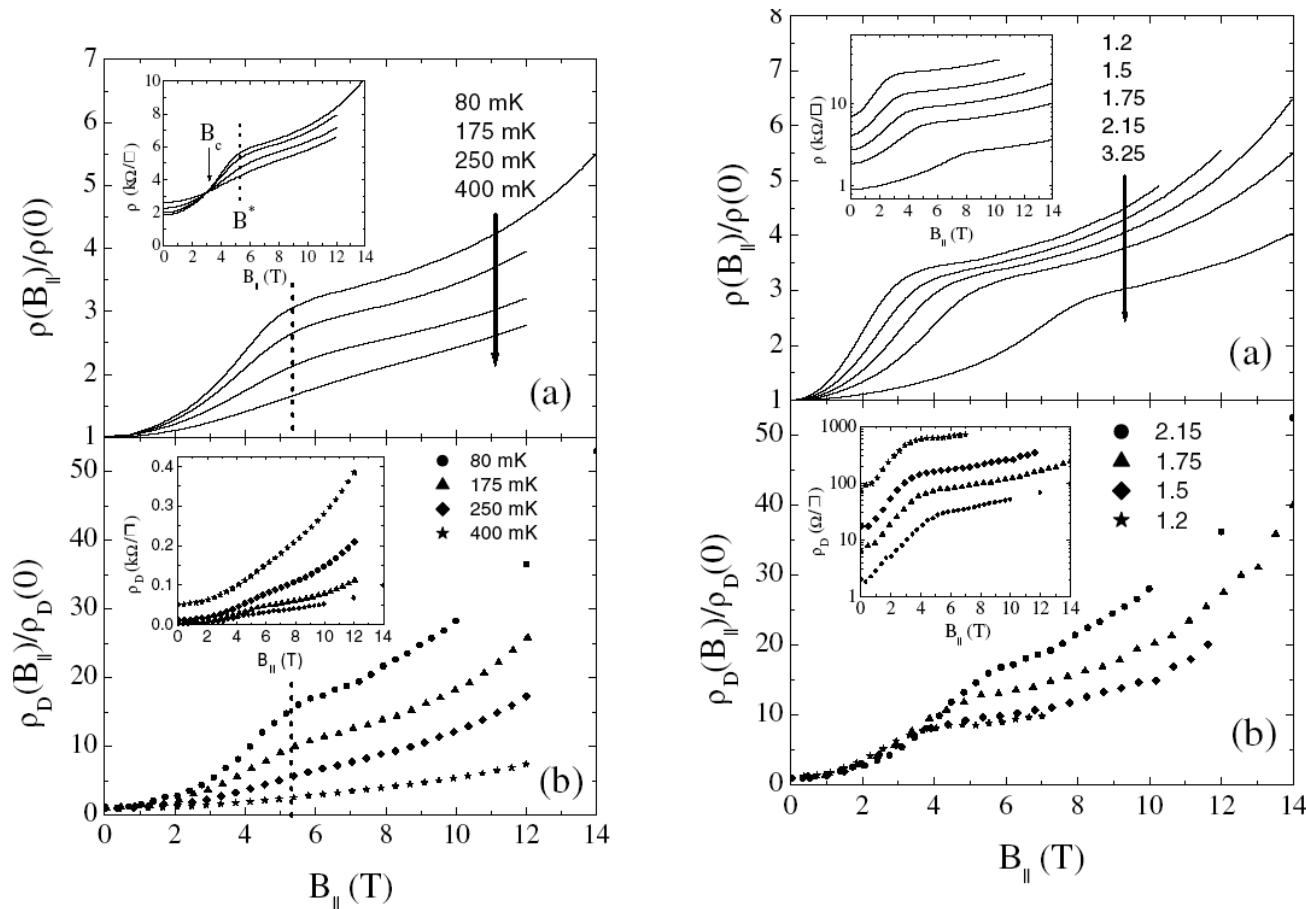


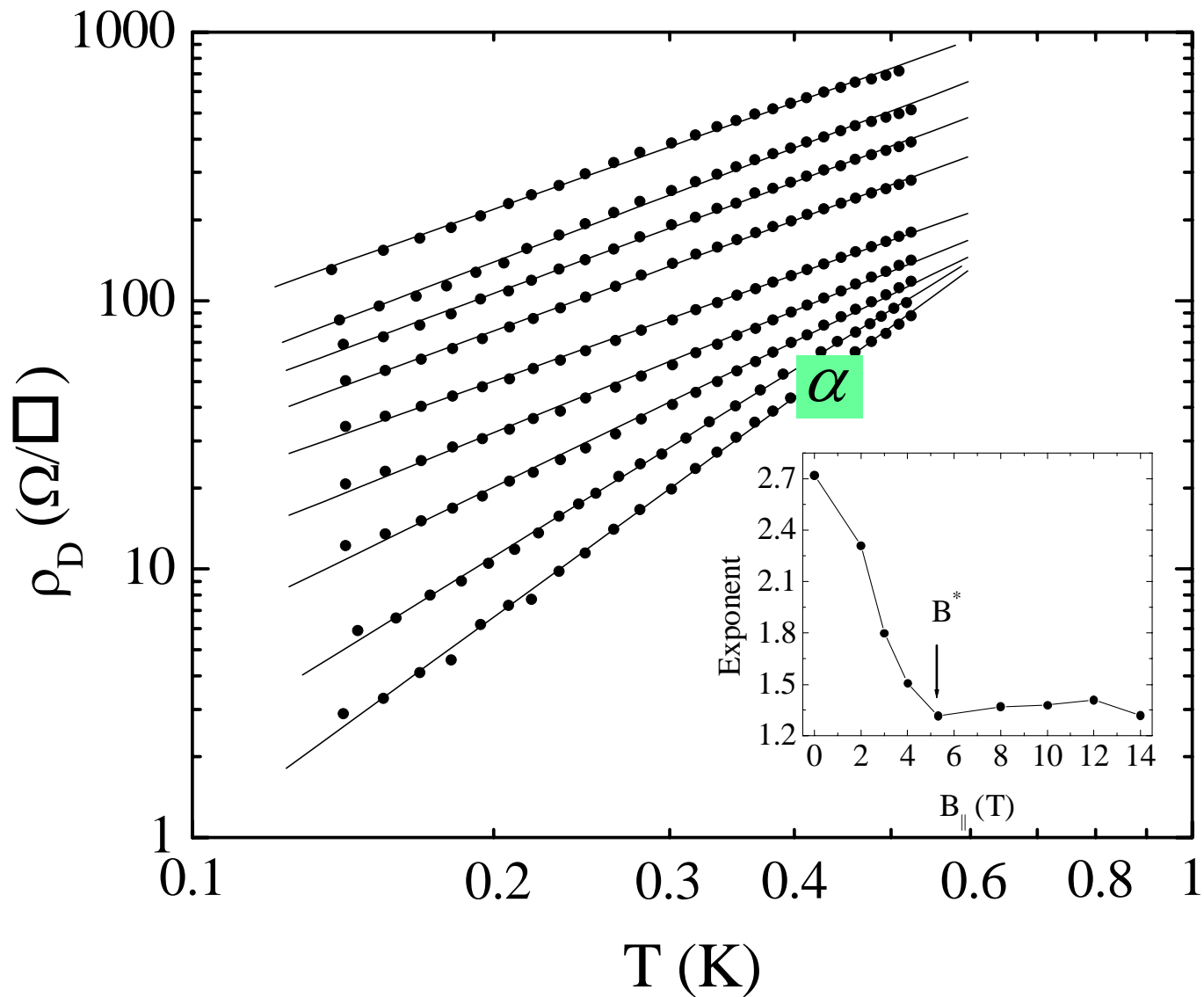
FIG. 1. In-plane magnetotransport data for $p_m = 2.15 \times 10^{10} \text{ cm}^{-2}$ at $T = 80, 175, 250,$ and 400 mK . (a) Inset: ρ vs B_{\parallel} . B_c and B^* are indicated by the arrow and the dashed line, respectively. Main plot: Data from inset normalized by its $B_{\parallel} = 0$ value. (b) Inset: Corresponding data for ρ_D vs B_{\parallel} . Main plot: Data from inset normalized by its $B_{\parallel} = 0$ value.

FIG. 2. ρ and ρ_D vs B_{\parallel} at $T = 80 \text{ mK}$ for different densities. (a) Inset: ρ vs B_{\parallel} for (from bottom to top) $p = 3.25, 2.15, 1.75, 1.5,$ and $1.2 \times 10^{10} \text{ cm}^{-2}$. Main plot: Data from inset normalized by its $B_{\parallel} = 0$ value. (b) Inset: ρ_D vs B_{\parallel} for (from bottom to top) $p_m = 2.15, 1.75, 1.5,$ and $1.2 \times 10^{10} \text{ cm}^{-2}$. Main plot: Data from inset normalized by its $B_{\parallel} = 0$ value. Density for each trace is indicated in the legend.

Pillarisetty et al.
PRL. **90**, 226801
(2003)

$$\rho_D = \frac{V_P}{I_A}$$

T-dependence of the drag resistance in double layers of p-GaAs at different B_{\parallel}



Pillarisetty et al.
PRL. **90**, 226801
(2003)

$$\rho_D \propto T^{\alpha}$$

If it is all business as usual:

Why the drag resistance is 2-3 orders of magnitude larger than those expected from the Fermi liquid theory?

Why is there such a strong T and B_{\parallel} dependence of the drag?

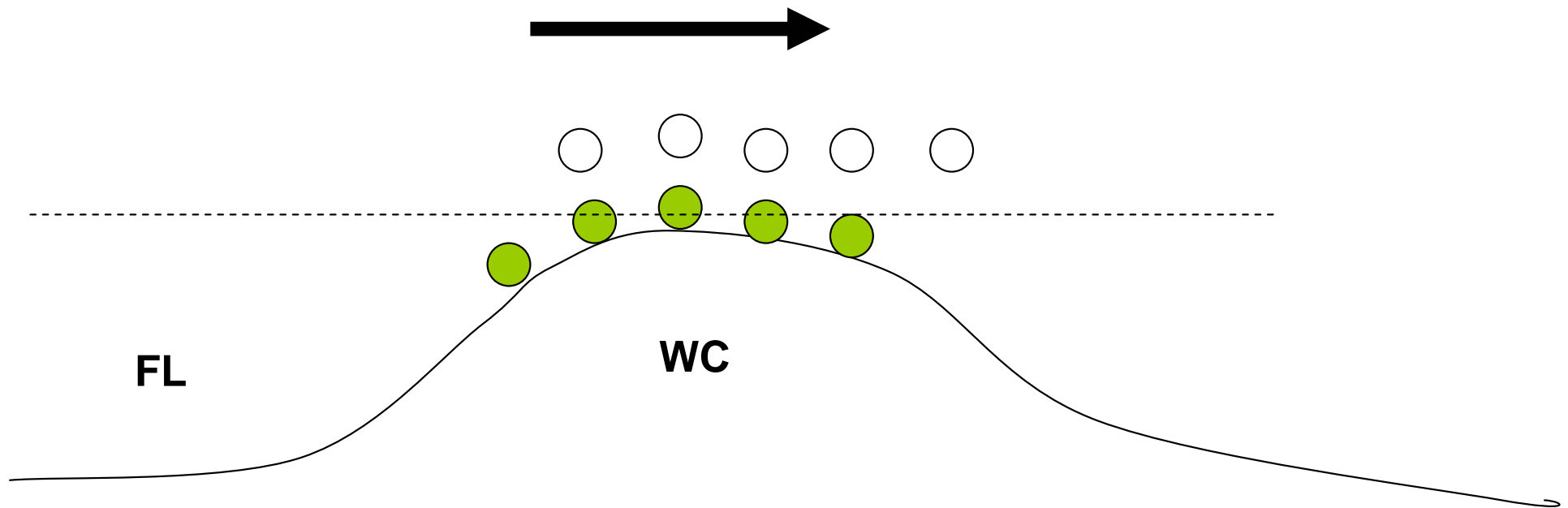
Why is the drag magneto-resistance positive at all?

Why does B_{\parallel} so effectively quench the T dependence of drag resistance?

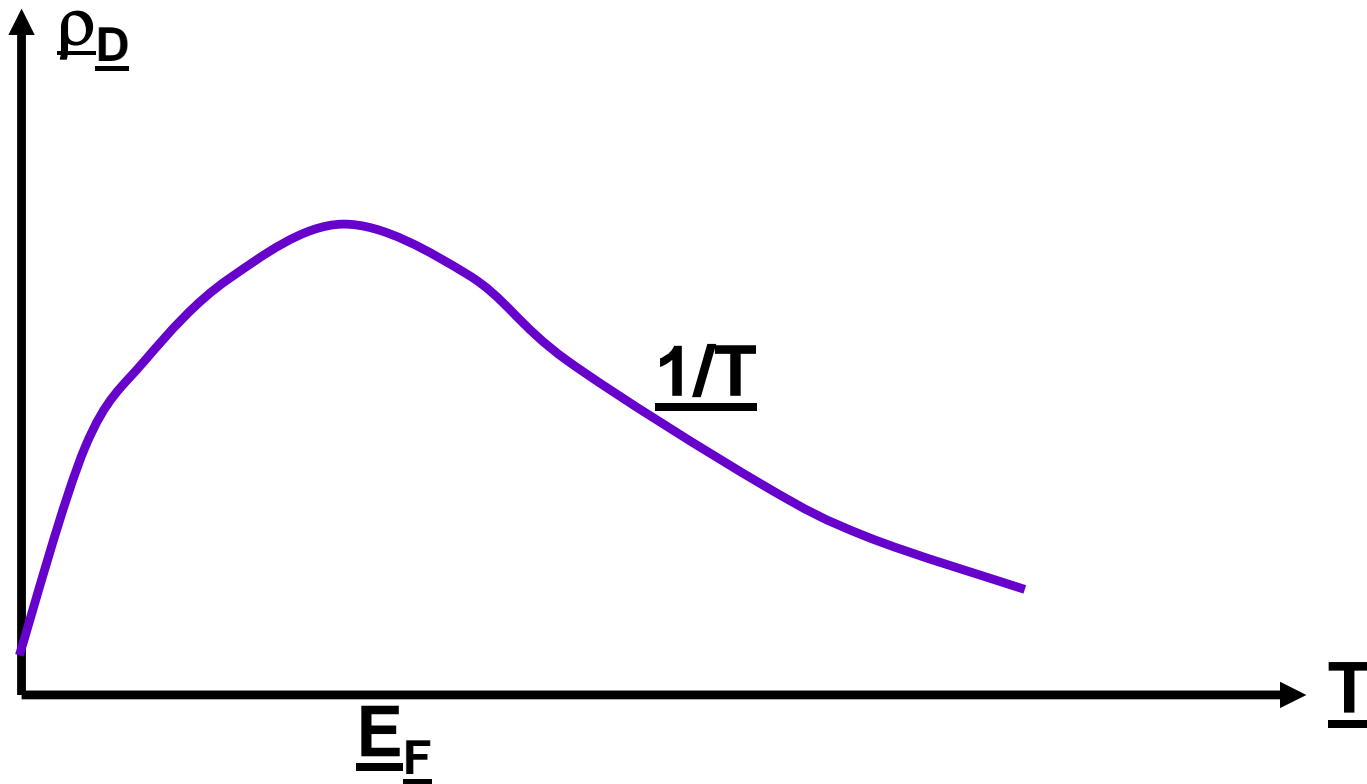
Why B_{\parallel} dependences of the resistances of the individual layers and the drag resistance are very similar

An open question: Does the drag resistance vanish at $T=0$?

The drag resistance is finite at $T=0$



A theoretical picture of the T dependence of the drag resistance in pure samples



Questions:

What is the effective mass of the bubbles?

What are their statistics?

Is the surface between the crystal and the liquid a quantum object?

Are bubbles localized by disorder?

effective droplet's mass m^*

At $T=0$ the liquid-solid surface is a quantum object.

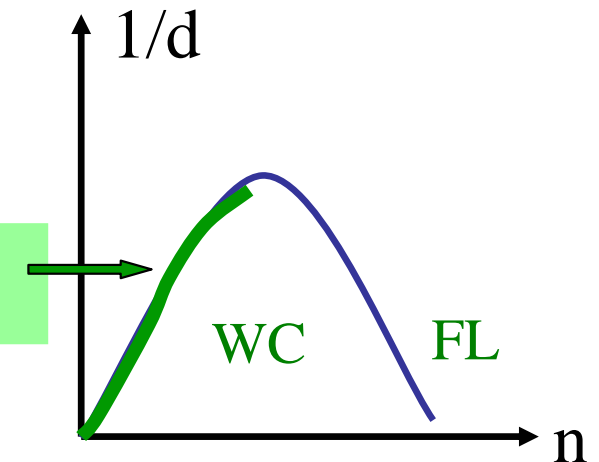
- a. If the surface is quantum smooth, a motion WC droplet corresponds to redistribution of mass of order

$$m^* \approx m n_c \pi R^2$$

- b. If it is quantum rough, much less mass need to be redistributed.

$$m^* \approx m(n_L - n_W) \pi R^2$$

$$nd^2 \approx 1; \quad m^* \approx m$$



In Coulomb case $m \sim m^*$

Properties of “quantum melted” droplets of Fermi liquid embedded in the Wigner crystal :

Droplets are topological objects with a definite statistics

The number of sites in such a crystal and the number of electrons are different .

Such crystals can bypass obstacles and cannot be pinned

This is similar to the scenario of super-solid *He* (A.F.Andreev and I.M.Lifshitz). The difference is that in that case the zero-point vacancies are of quantum mechanical origin.

Conclusion:

There are pure 2D electron phases which are intermediate between the Fermi liquid and the Wigner crystal .

(Unsolved problems):

1. Quantum hydrodynamics of the micro-emulsion phases.
2. Quantum properties of WC-FL surface. Is it quantum smooth or quantum rough? Can it move at $T=0$?
3. What are properties of the microemulsion phases in the presence of disorder?
4. What is the role of electron interference effects in 2D microemulsions?
5. Is there a metal-insulator transition in this systems?
Does the quantum criticality competes with the single particle interference effects ?